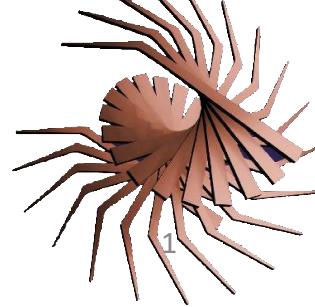


# Week 13

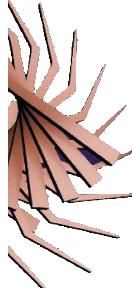
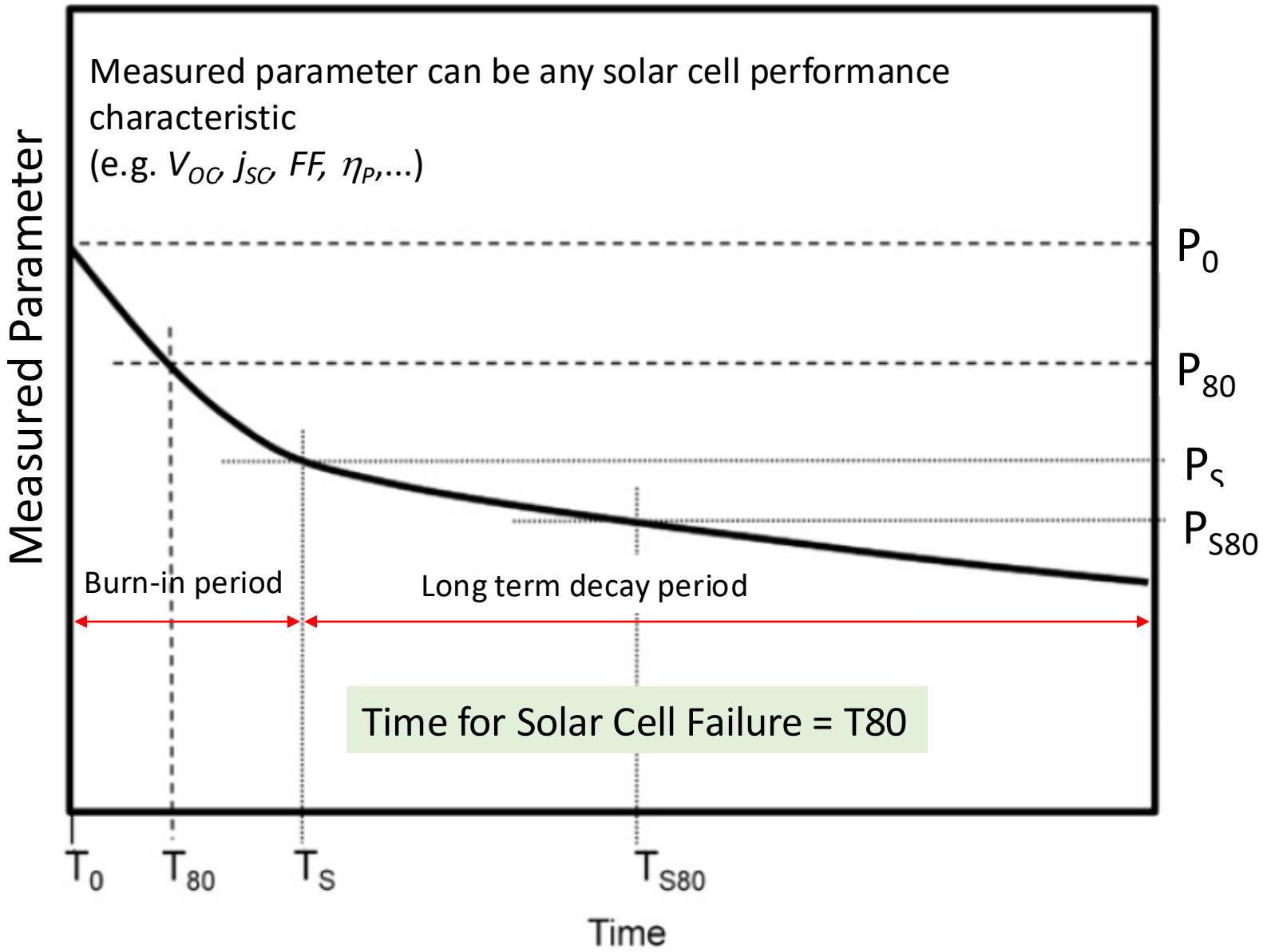
## Organic Photovoltaics 2

Reliability  
Modules  
Chapter 8.6 – 8.7

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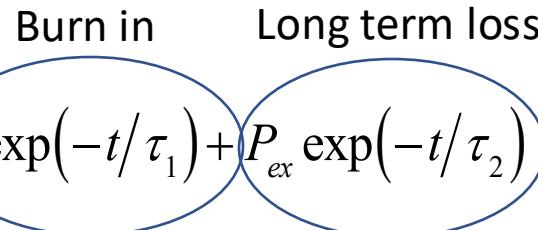
# Quantifying OPV Lifetimes



# Analytical Approaches to Failure

(see also Ch. 6.7)

Sum of Exponentials:  $P(t) = P_0 \exp(-t/\tau_1) + P_{ex} \exp(-t/\tau_2)$



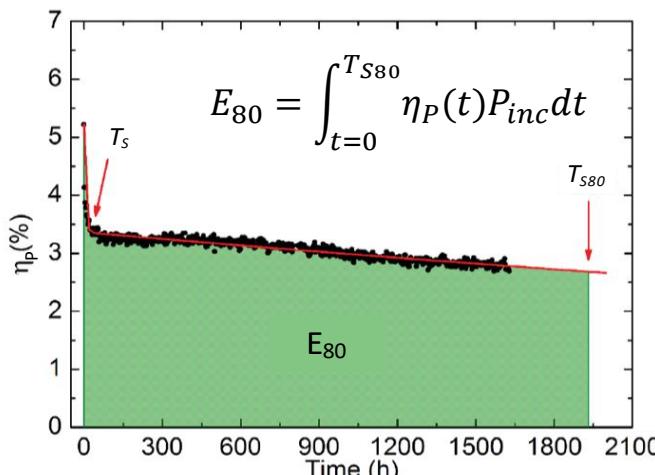
Stretched Exponential:  $P(t) = P_0 \exp[-(t/\tau_1)^\beta]$

Degradation rate:  $k_{deg} = 1/\tau = k_0 \exp(-E_a/k_B T)$

$E_a$  = thermal activation of degradation rate,  $k_{deg}$

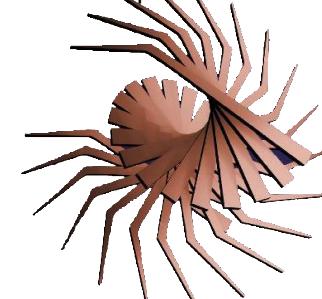
Acceleration Factor:  $\mathcal{A} = \left( \frac{P_{inc}^1}{P_{inc}^2} \right)^\gamma \exp\left[ -\frac{E_a}{k_B} \left( \frac{1}{T_1} - \frac{1}{T_2} \right) \right]$

Total energy generated:

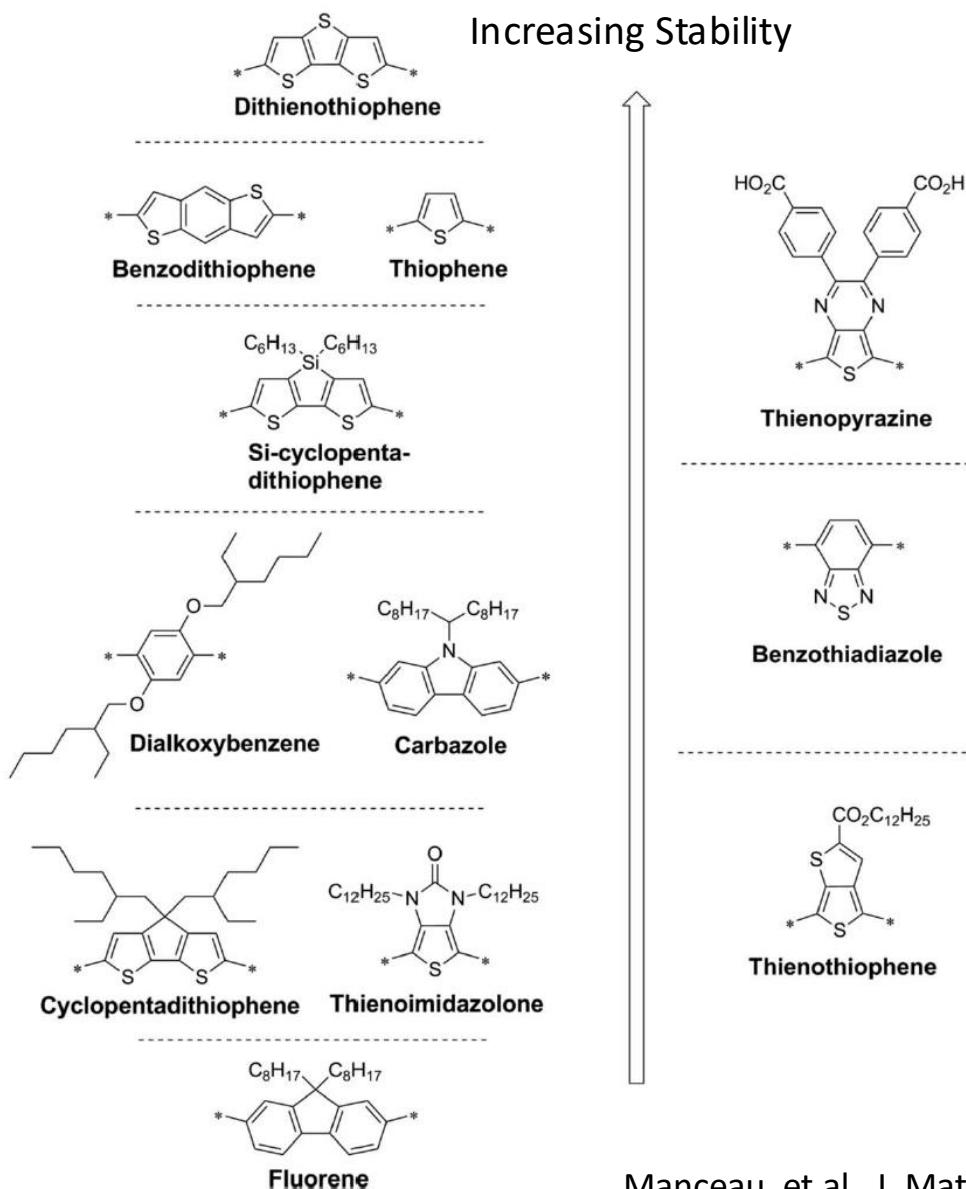


(assumes life begins after burn-in)

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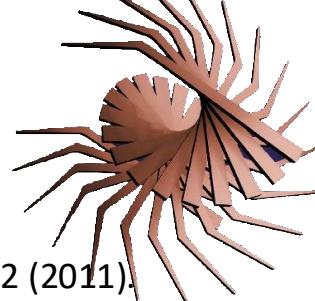


# Choice of Molecules Impacts Stability

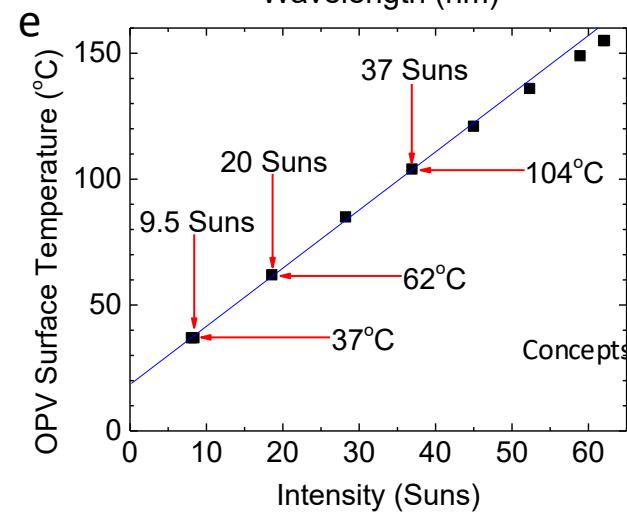
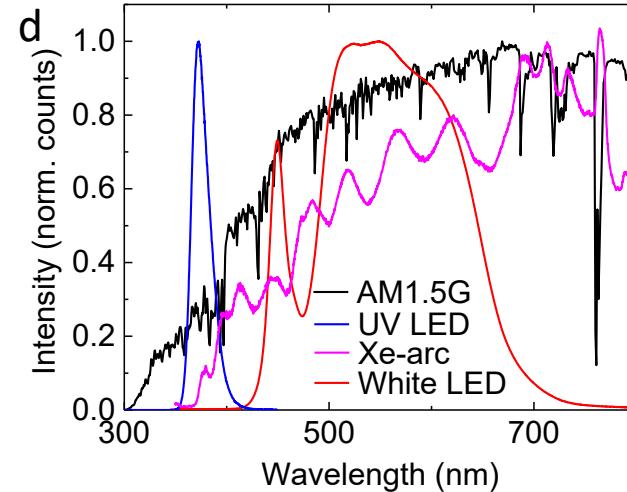
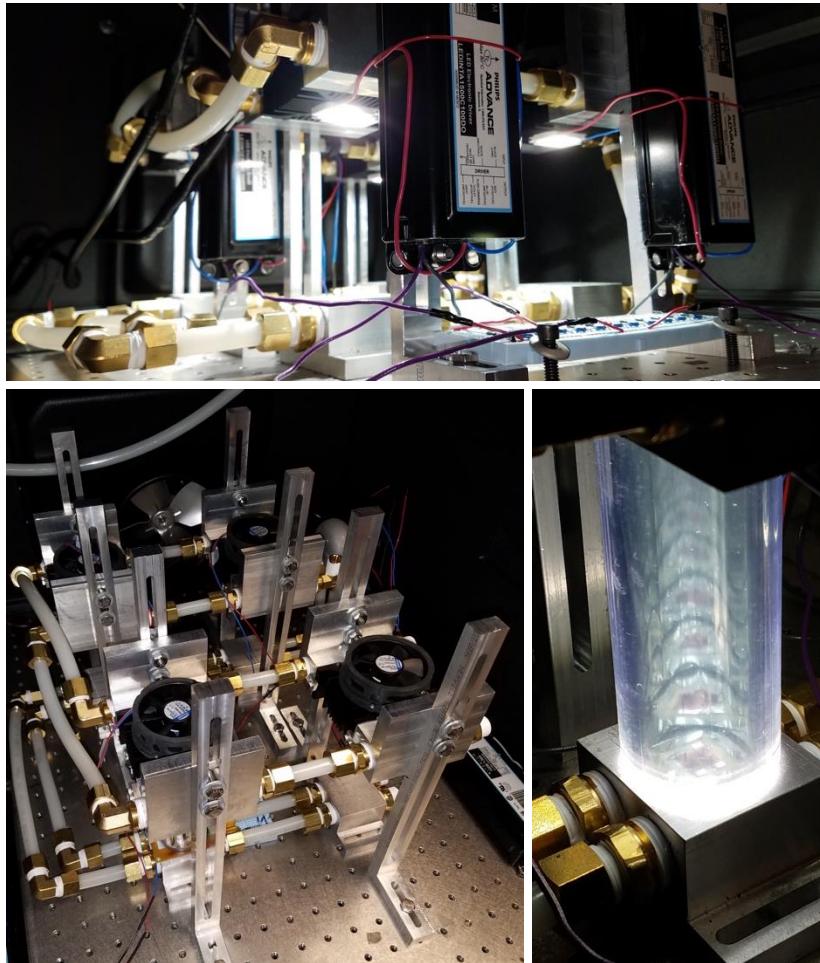


Manceau, et al., J. Mater. Chem., **21**, 4132 (2011)

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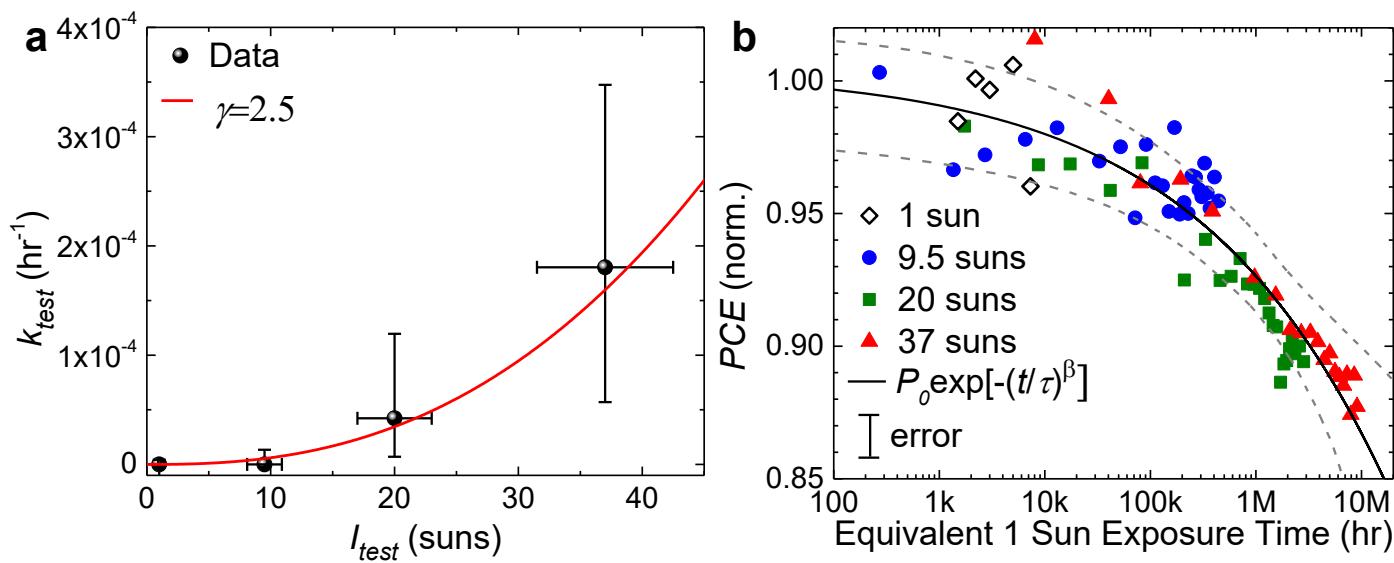
# Test set up for Accelerated Aging



Populations of devices under very high intensity illumination using LEDs

Need to separate effects of temperature and intensity acceleration factors

# Extracting Lifetime from Aging Data & Acceleration Factors

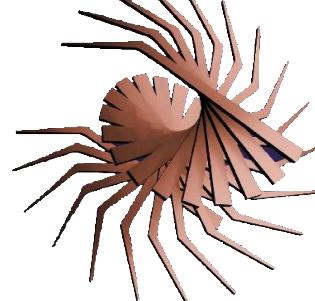


Extrapolated *intrinsic* lifetime:  $>10^4$  years!

Metric for failure: T80; 5 h = 1 day solar equivalent

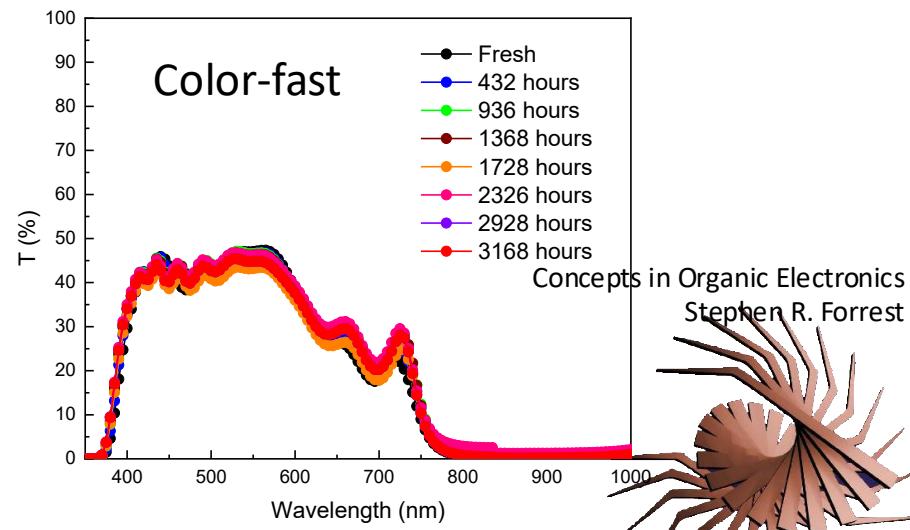
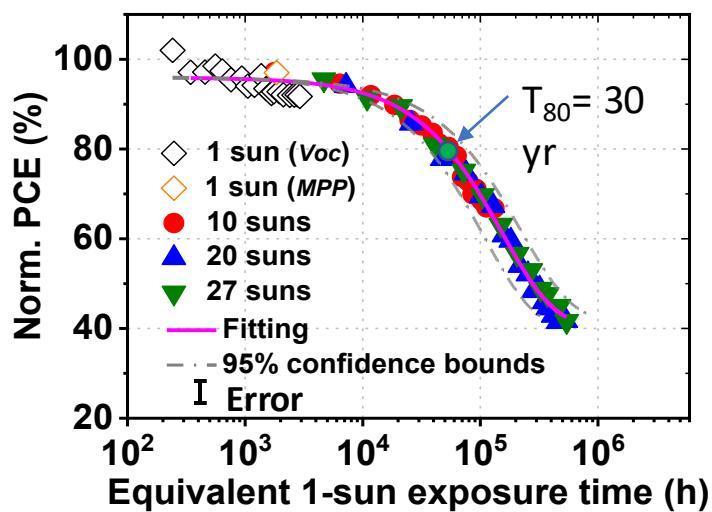
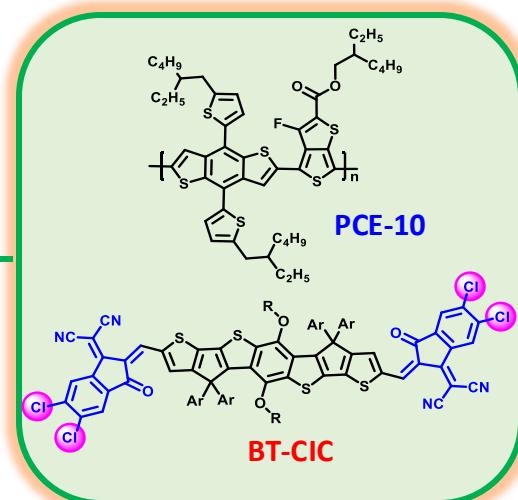
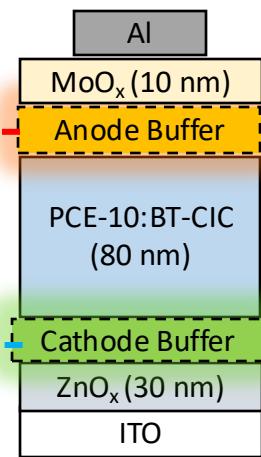
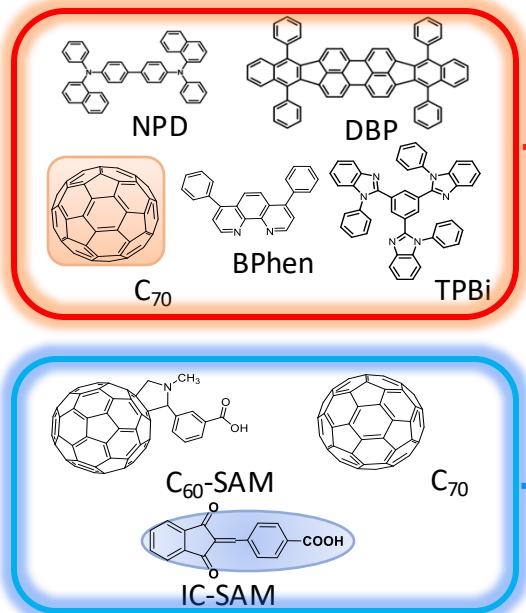
Q. Burlingame, et al., Nature, 573, 394 (2019).

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# NFA OPVs Can Also Have Long Lifetimes

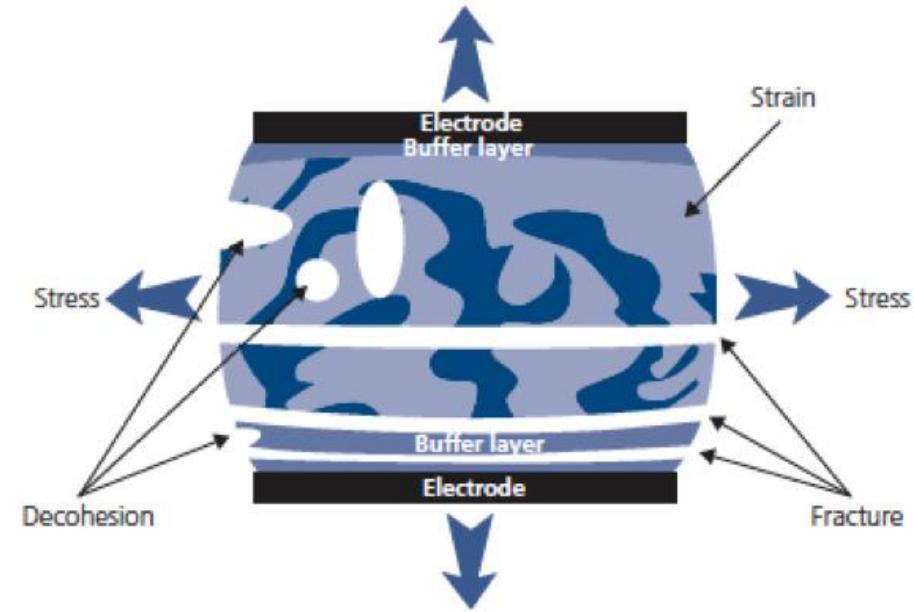
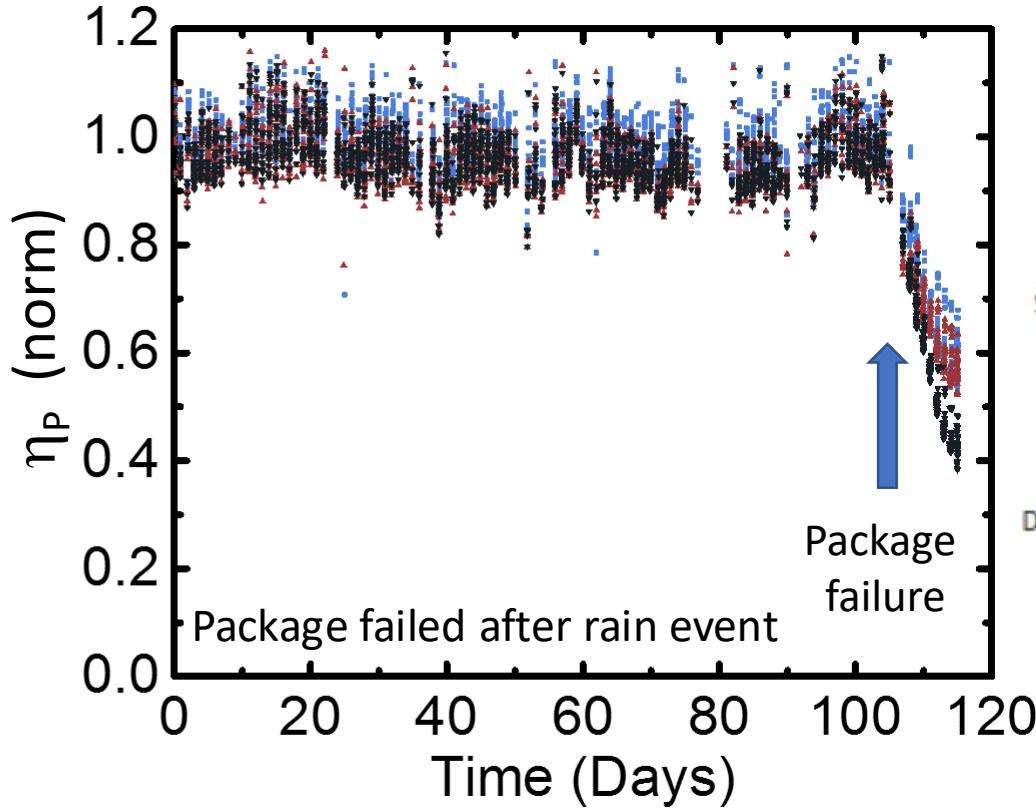
PCE  $\sim 12\%$



# What happens outdoors

Examining reliability in a real operating environment

1:8 DBP:C<sub>70</sub> OPV

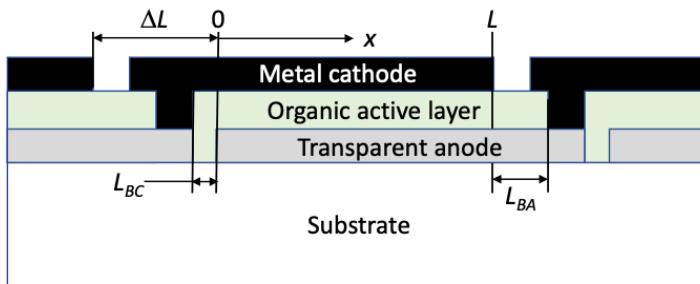


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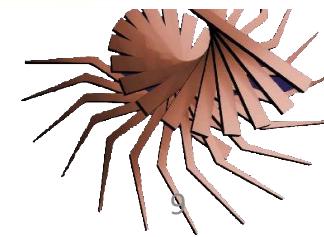
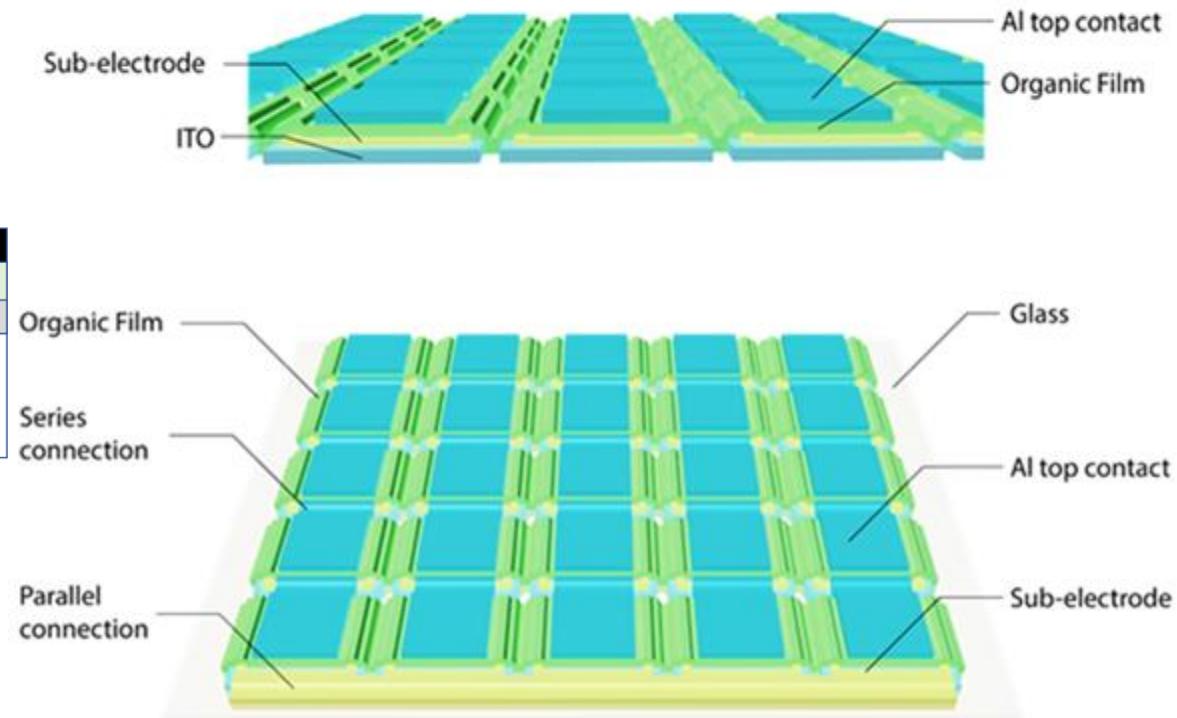
Ultimately, solar cell reliability depends on materials, morphologies and test conditions in actual environments

# Scaling to Modules

Series connected cells

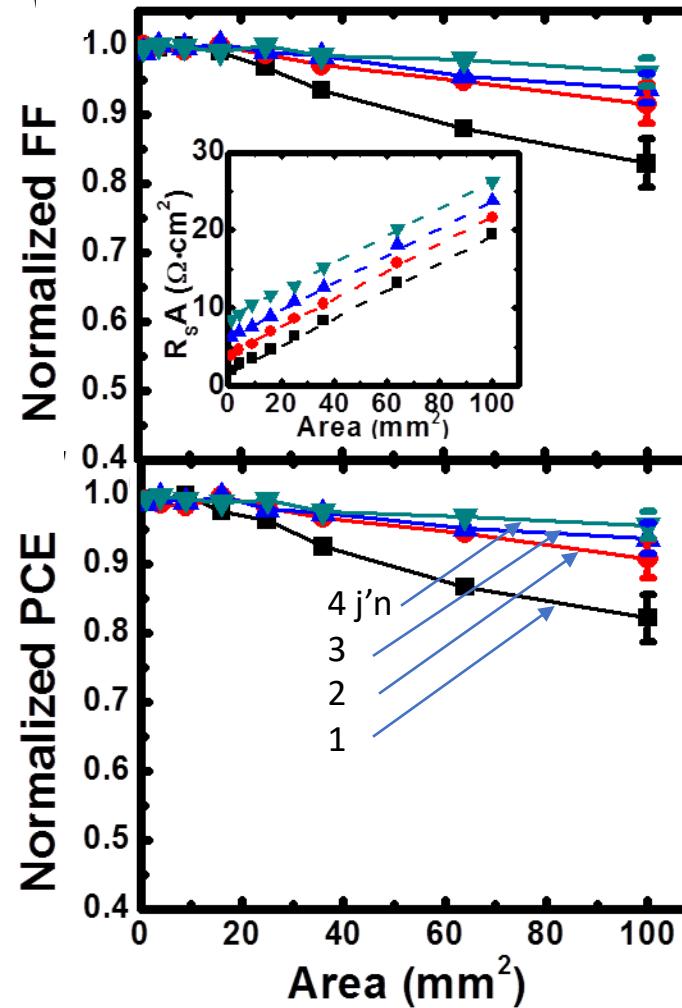


Series-parallel connected tandem OPVs

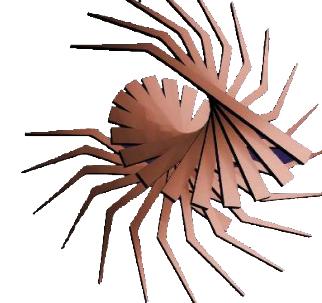


# Multijunction Cells Limit the Effects of Resistance

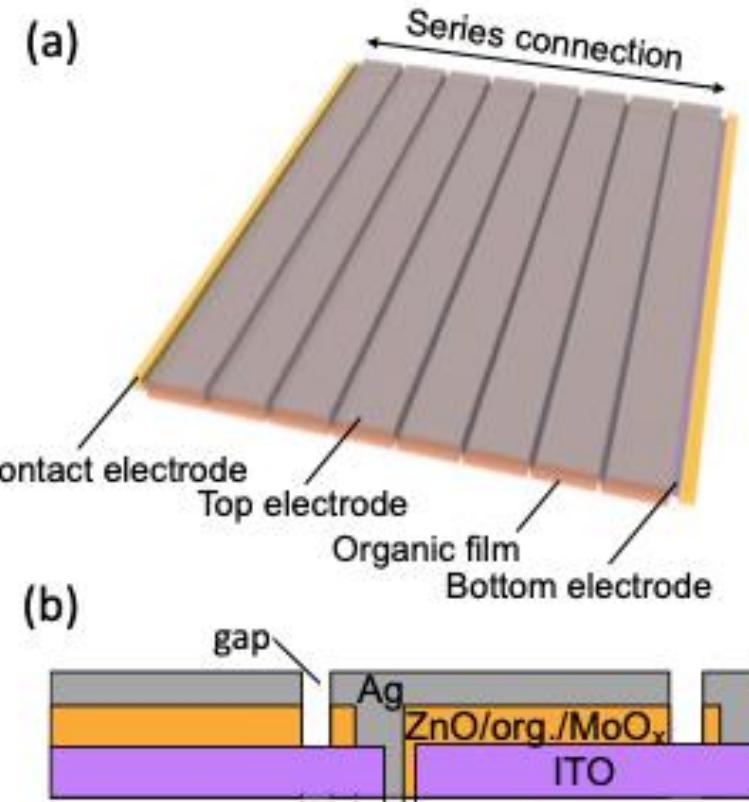
The higher the voltage,  
The smaller the problem  
⇒ Multijunction cells



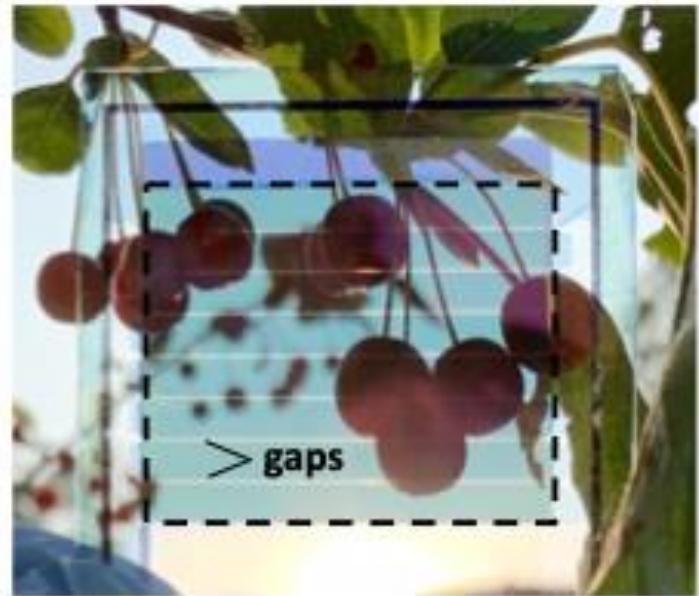
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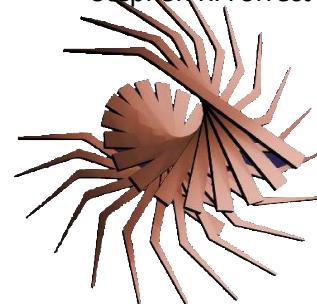
# ST-OPV Module



Long PV stripes equivalent to parallel connection

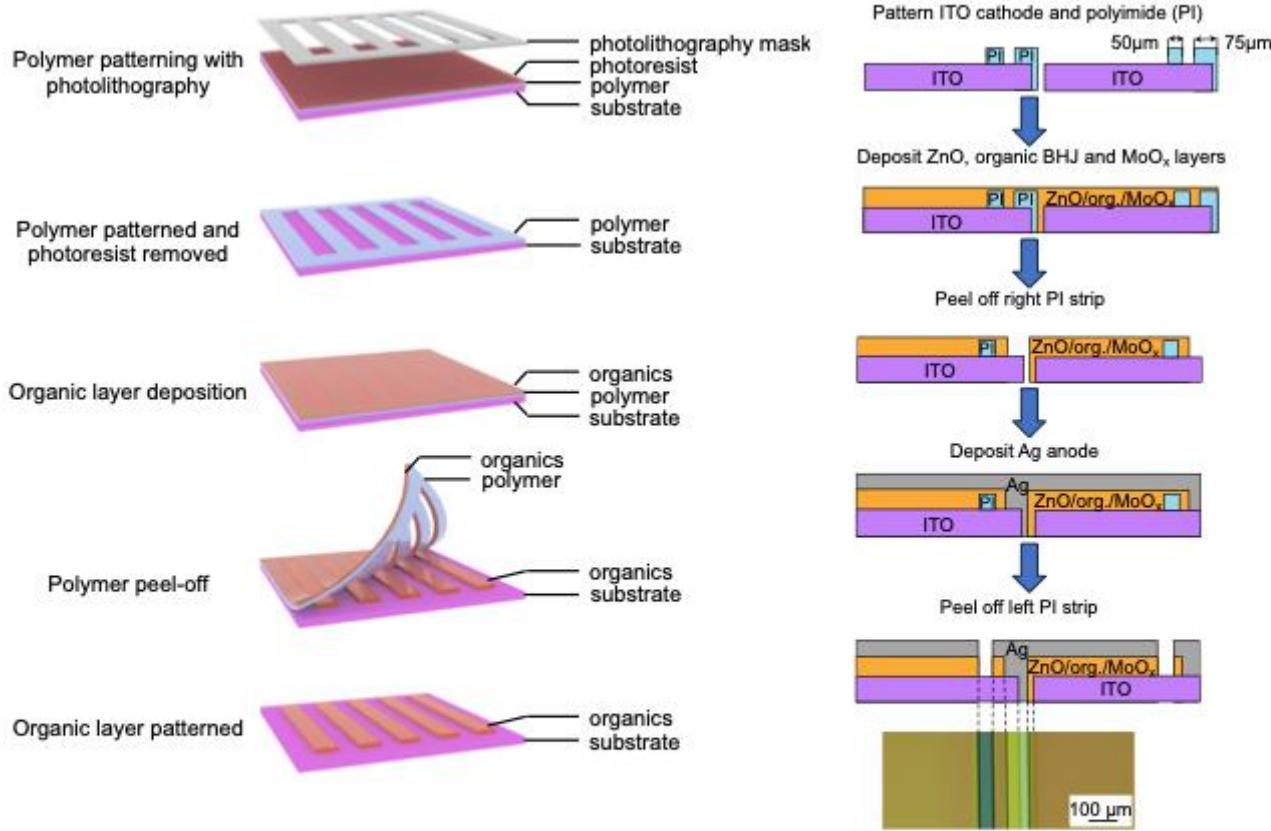


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# Fabricating modules

- Peel off patterning

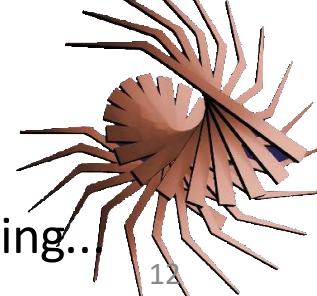


X. Huang, et al. (2022). Joule, 6, 1581

Other methods:

Laser scribing, shadow masking, slot-dye coating, mechanical scribing..

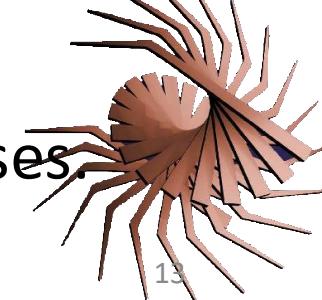
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# What we learned about OPDs and OPVs

- Photogeneration in OPDs and OPVs mediated by charge transfer at D-A HJs
- Bulk heterojunctions break the tradeoff between a "long" optical absorption length and short exciton diffusion length.
  - Morphology control essential to high device performance
  - Multijunction cells free efficiency from the single junction thermodynamic limit
- OPDs generally operated in the 3<sup>rd</sup> quadrant to minimize dark current, and hence noise. OPVs operated in the 4<sup>th</sup>, power-generating quadrant.
- Visible-transparent, NIR absorbing cells the most promising application for OPVs: power generating windows, agrivoltaics
- Cell reliability can extend to  $\gg 50$  years in some cases.
- Modules primarily limited by series resistance

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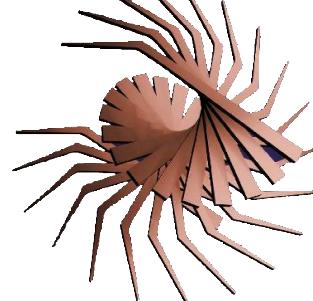


# Organic Thin Film Transistors

## Thin Film Transistors 1

Transistor Basics  
Conventional Transistor Architectures  
Operating Characteristics  
Chapter 9.1-9.2

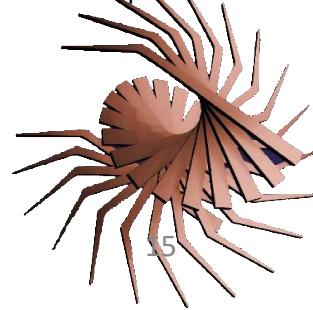
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# OTFT Objectives

- Learn how they work
- Learn how they are made
- Learn about their operational reliability
- Learn what they are good for: Are they an answer waiting for a question?
  - Sensing
  - Medical Applications

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# Advantages vs. Limitations of OTFTs

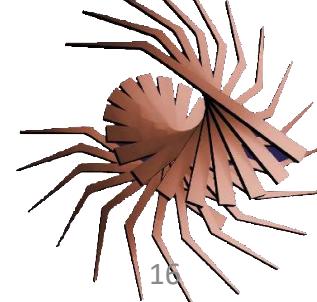
- PROs

- Flexible, conformable, ultralight
- Can be made over very large areas
- Suitable for large scale R2R manufacture

- CONs

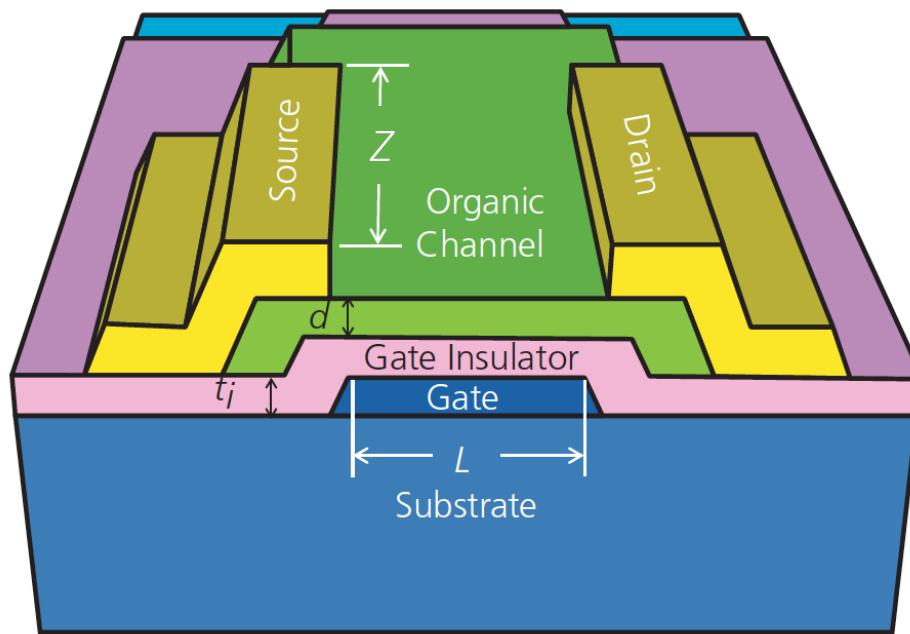
- Cannot source large currents
- Characteristics drift over long periods in operation
- Limited bandwidth ( $\leq 1$  MHz in many cases)

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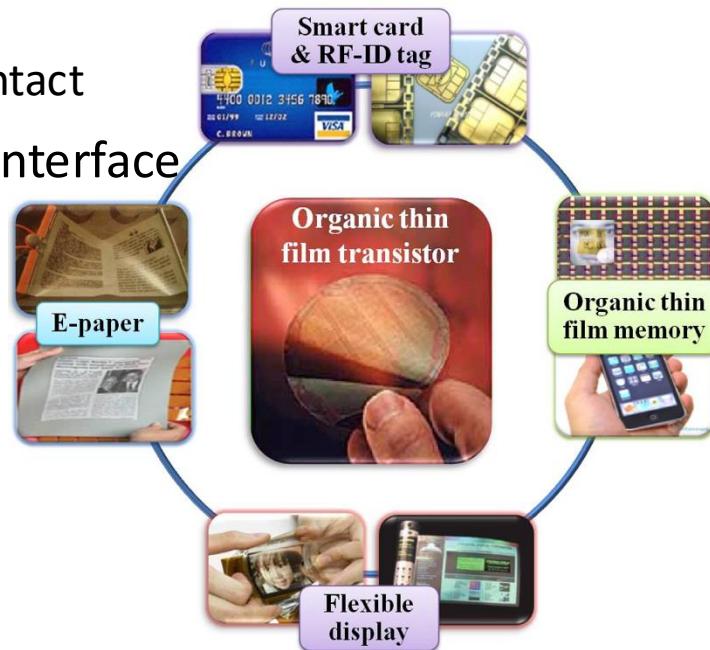


# What an OTFT looks like

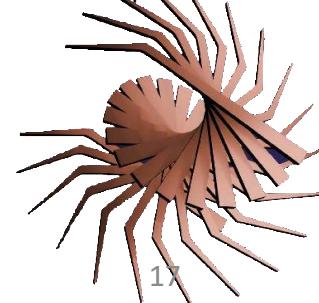
- Several different configurations
  - Bottom gate, top gate, bottom SD contact, top SD contact
- Properties strongly influenced by dielectric/organic interface
- Configuration similar to inorganic TFTs
  - Metal oxide
  - a-Si
  - Etc.



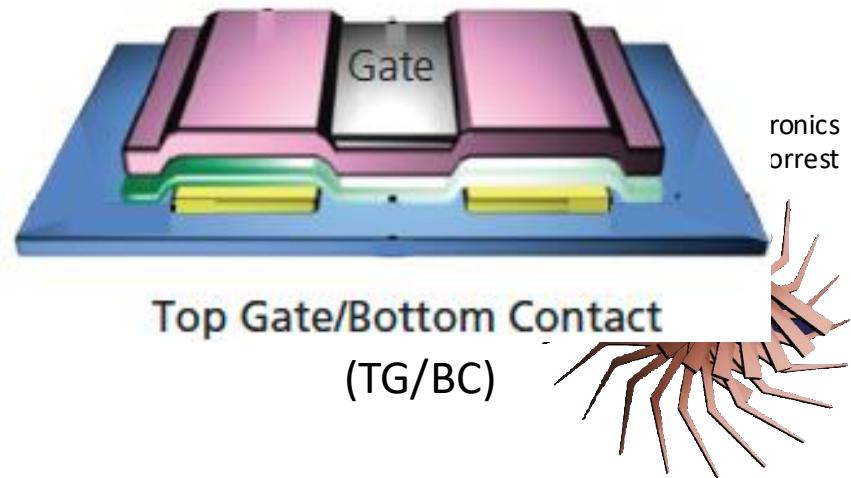
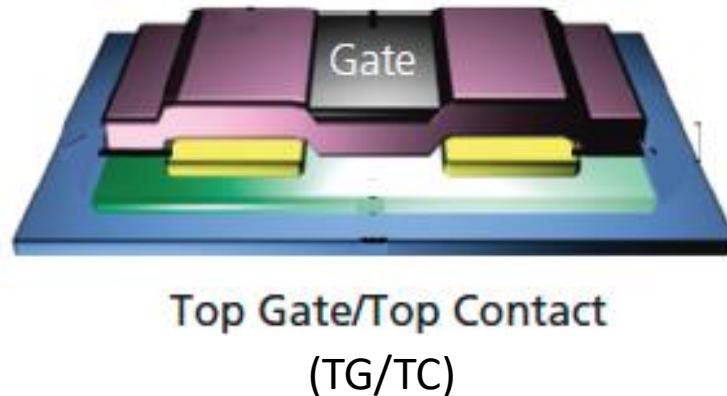
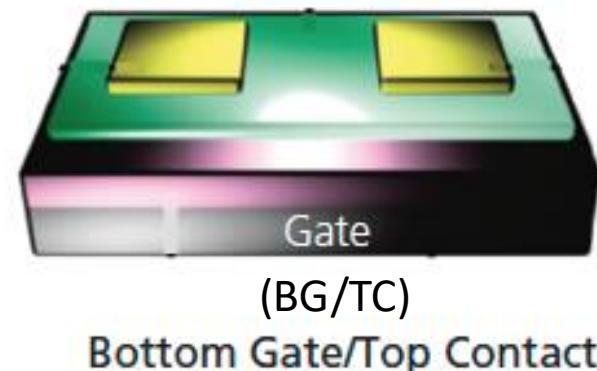
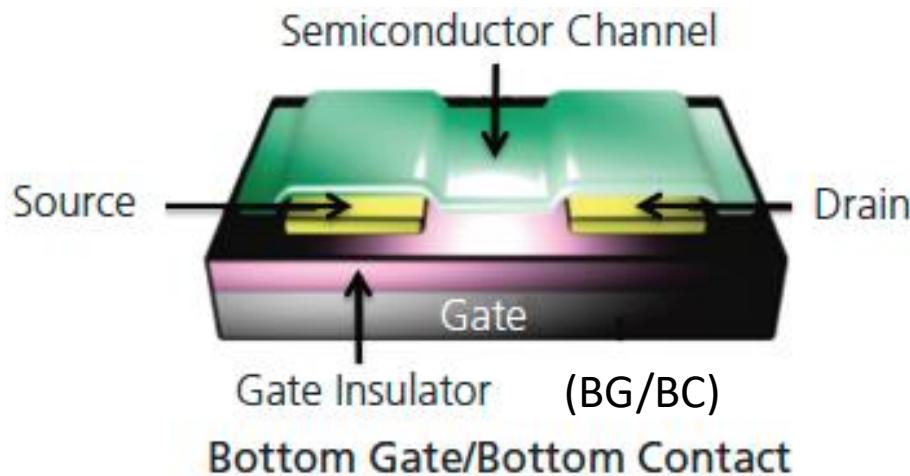
Definitions of Contacts and Dimensions



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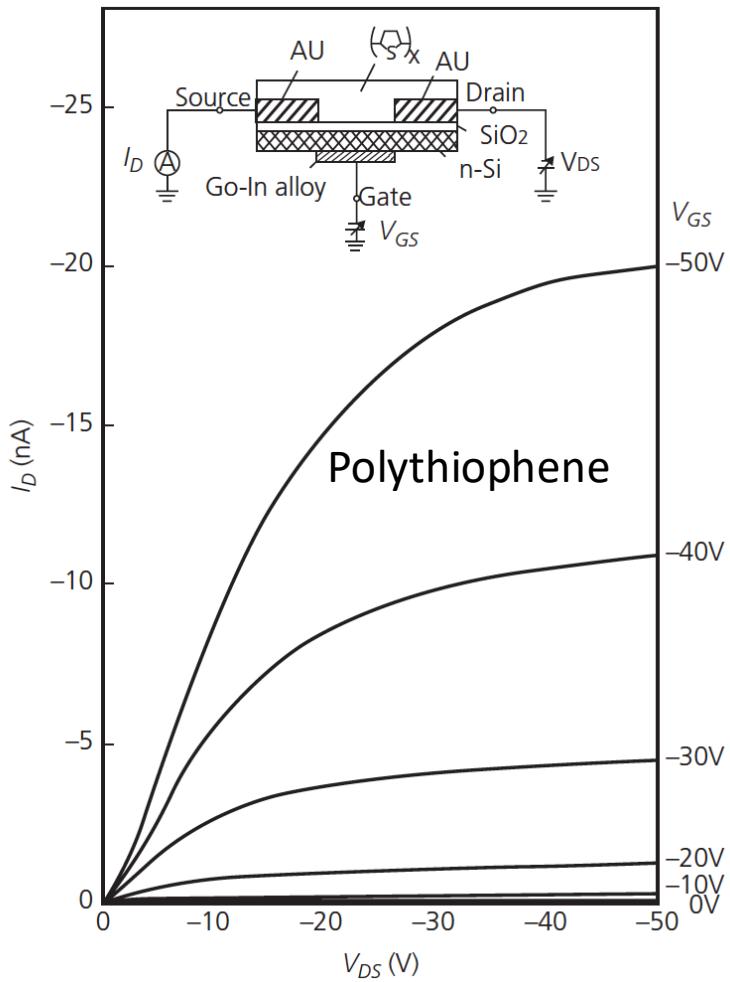


# Different Contact Arrangements

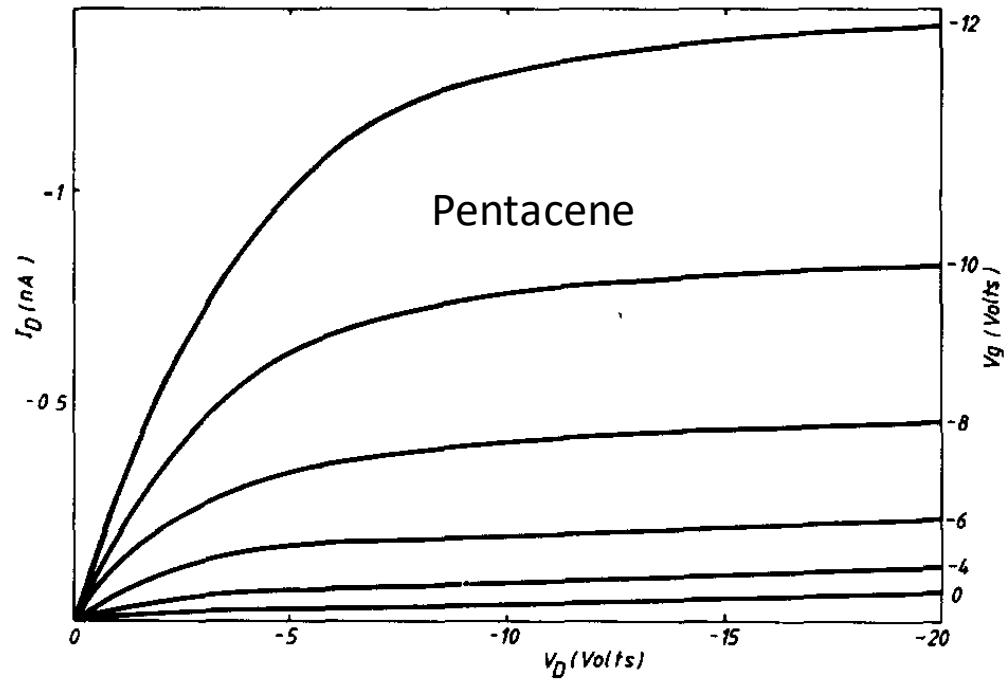


# Organic Thin Film Transistors

## First demonstrations

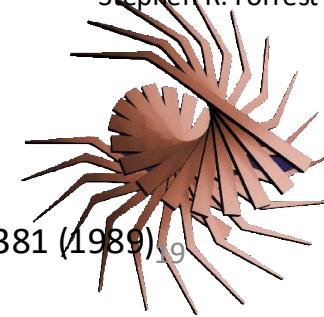


A. Tsumura, et al., Appl. Phys. Lett., 1210, 49 (1986)

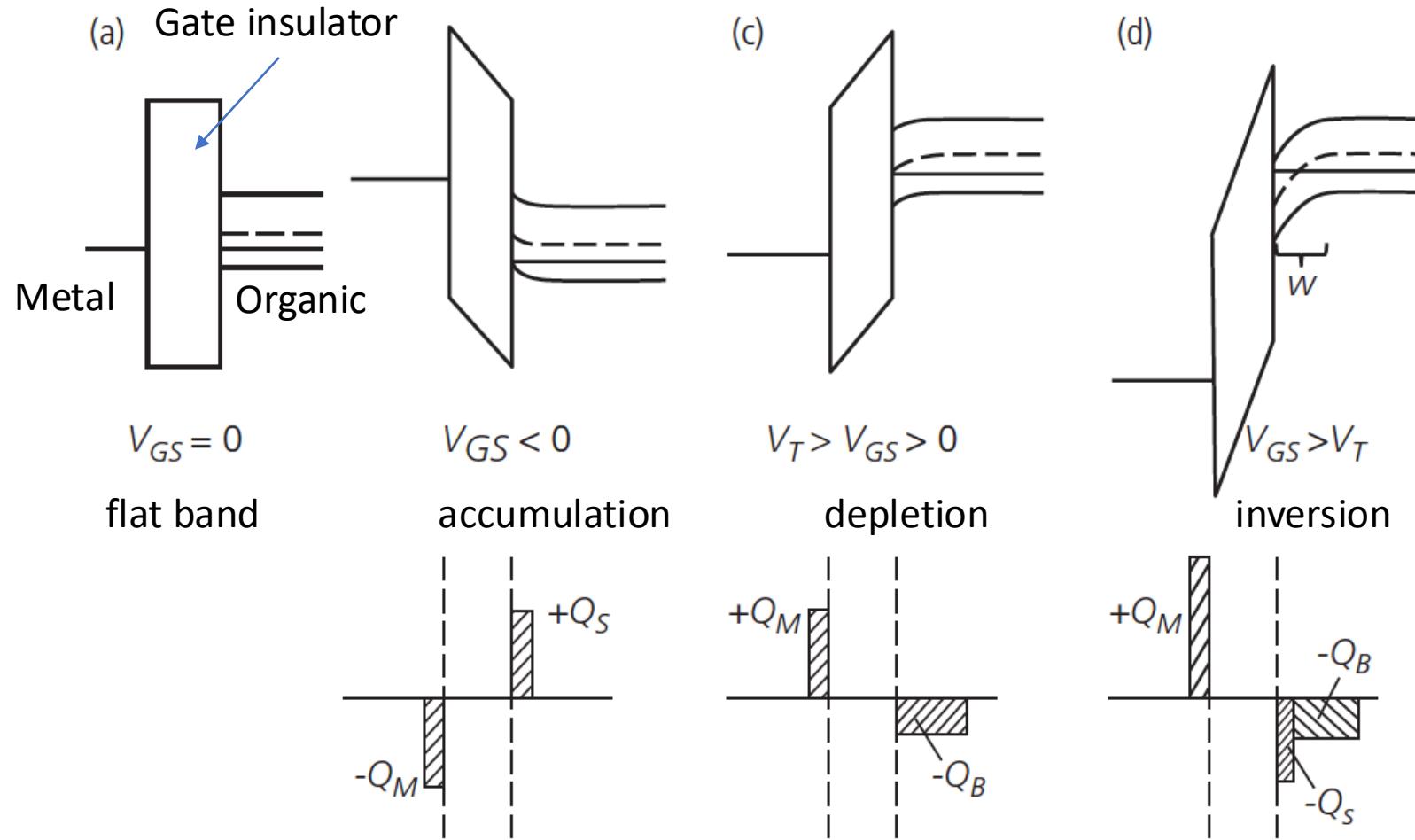


G. Horowitz, et al., Solid State Commun., 72 381 (1989)

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# The MIS Capacitor: OTFT Building Block



- Organics often have little charge in the bulk of the semiconductor  $\Rightarrow$  no band bending
- Charge drawn into channel from source to allow conduction at the insulator/org. interface

# How an OTFT Works: Accumulation

Charge injected from the source by a gate voltage,  $V_{GS}$ , at very low drain voltage,  $V_D$ , and hence low channel current (i.e. ohmic):

$$Q(x) = qn(x)t = C_G(V_{GS} - V(x))$$

Charge layer thickness

But contact resistance and potential, charge trapping, grain boundaries, etc. prevent channel conduction until a threshold voltage  $V_T$  is reached:

$$Q(x) = qn(x)t = C_G(V_{GS} - V_T - V(x))$$

Following Ohm's Law:

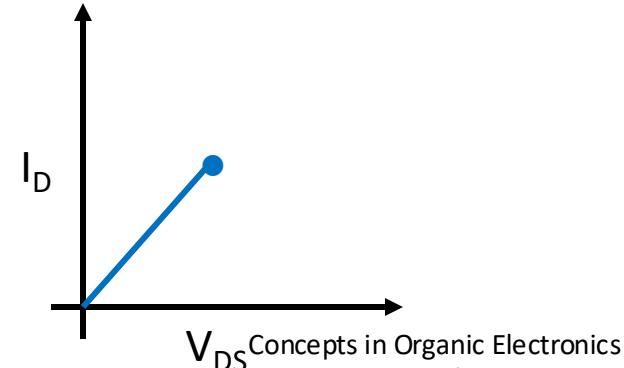
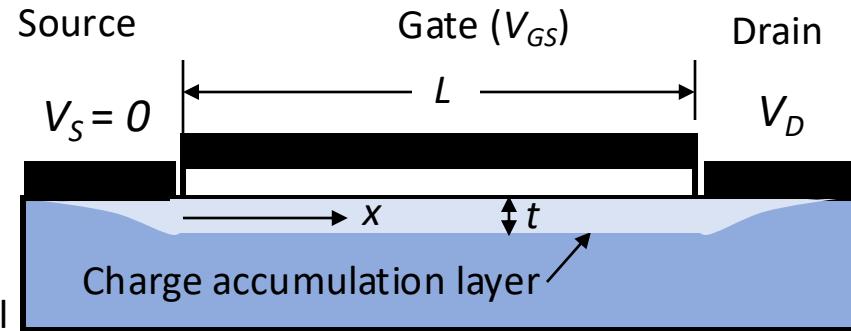
$$I_D = A\sigma F = W(n_{ave}qt)\mu \frac{V_D}{L}$$

$Q_{ave}$

At low voltage, conduction is ohmic  $\Rightarrow$  we can use the average channel voltage drop  $V_D/2$ .

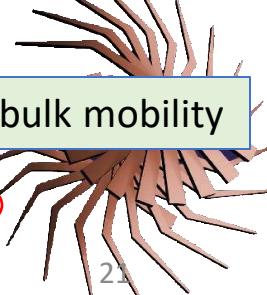
Or, in the linear regime of operation:

$$I_D = \frac{W}{L} C_G \mu \left( V_{GS} - V_T - \frac{V_D}{2} \right) V_D = \frac{W}{L} C_G \mu \left( (V_{GS} - V_T)V_D - \frac{V_D^2}{2} \right)$$



Field-effect mobility is **not** bulk mobility

$$\mu = \mu_{FE}$$



# In the Saturation Region

In the linear regime ( $V_G - V_T \gg V_D$ ), we calculate the transconductance:

$$g_m = \frac{\partial I_D}{\partial V_{GS}} \Big|_{V_D} = \frac{W}{L} C_G \mu_{lin} V_D$$

And the output conductance:

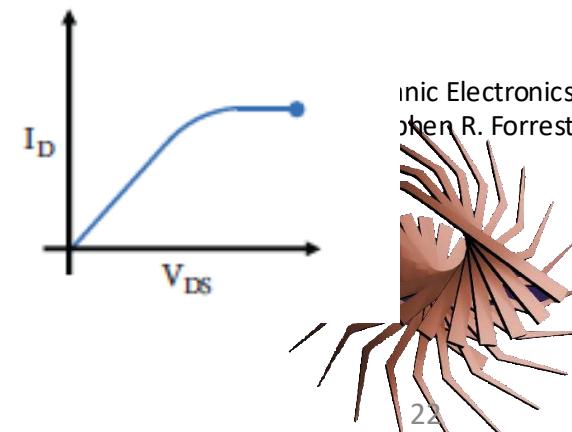
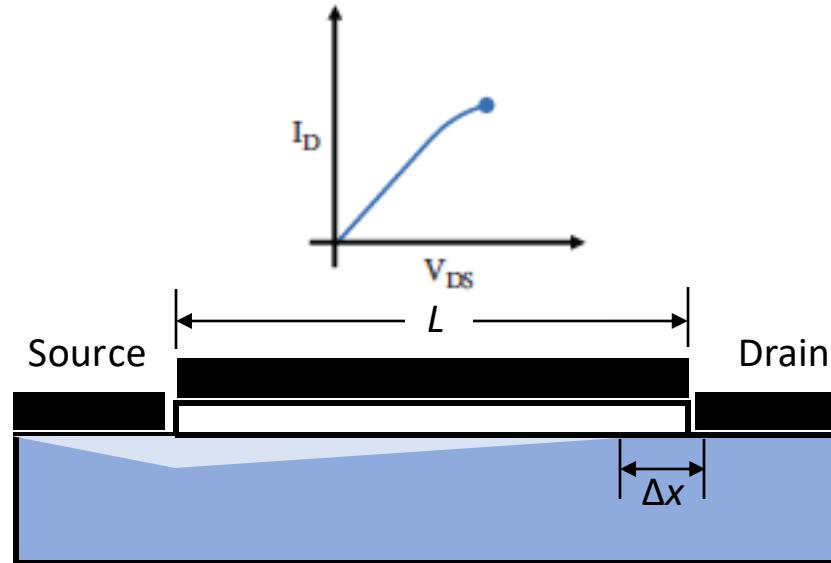
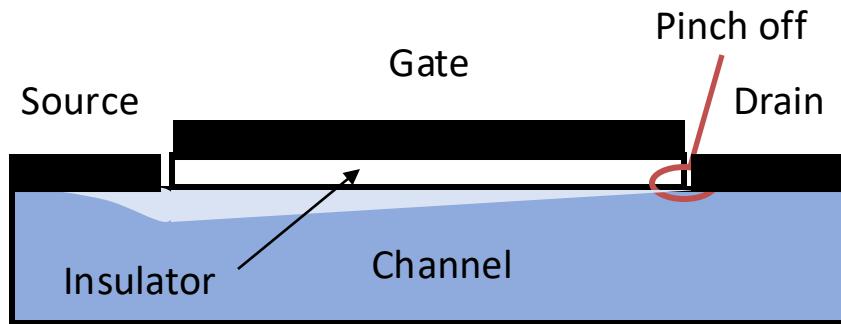
$$g_D = \frac{\partial I_D}{\partial V_{DS}} \Big|_{V_G} = \frac{W}{L} C_G \mu_{lin} (V_G - V_T)$$

Due to contact & other parasitic resistances,  $\mu_{lin}$  gives errors, so mostly use saturation characteristics:

- When  $V_D = V_G - V_T$ , the channel **pinches off**
- Between pinchoff point and drain,  $n \rightarrow 0 \Rightarrow F \rightarrow$  large to maintain current continuity ( $j = nq\mu F$ )
- No more current (except leakage) enters channel with increasing  $V_D$ , hence we are in the saturation regime.

Then:  $I_D = \frac{W}{2L} C_G \mu_{sat} (V_G - V_T)^2$

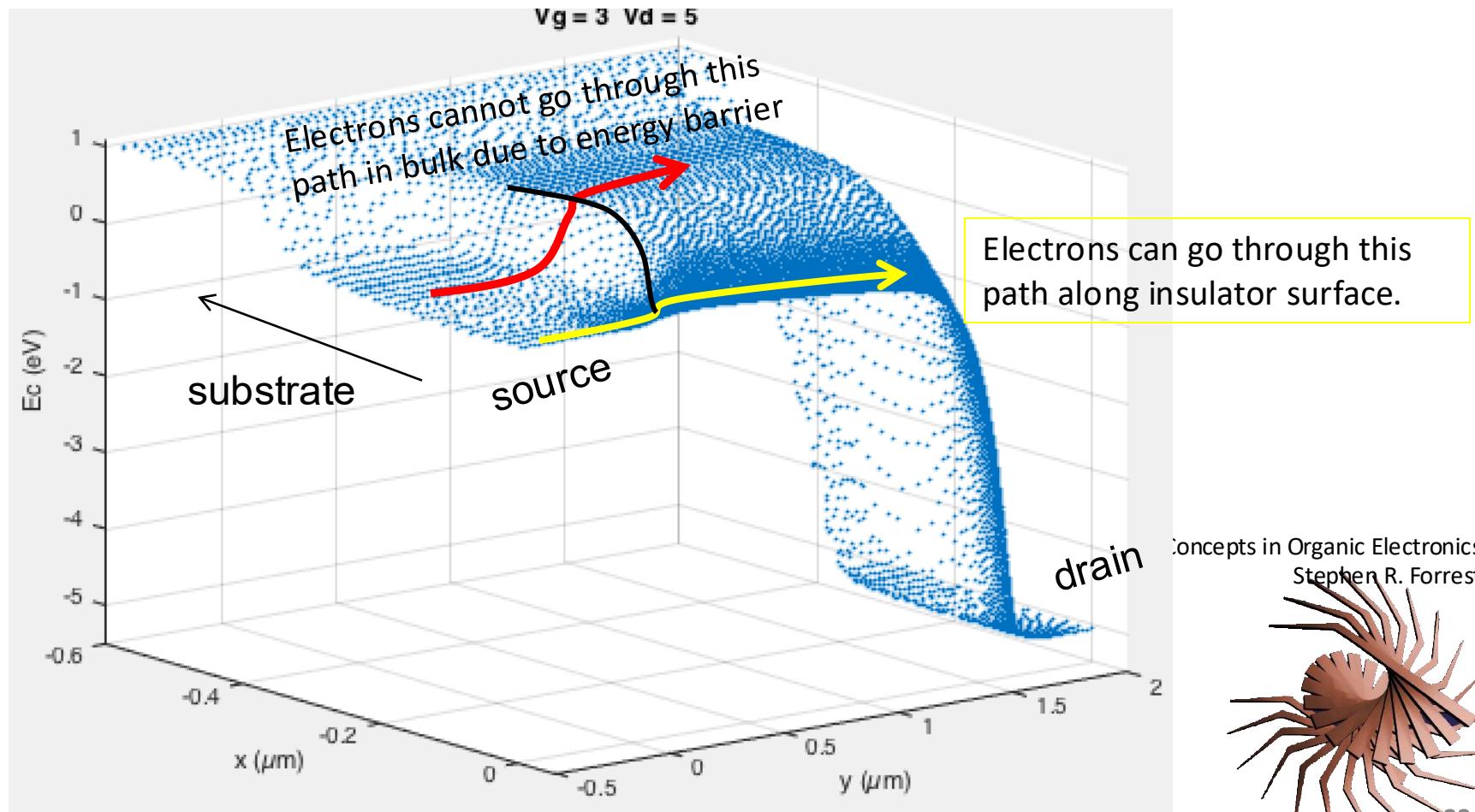
Plot of  $I_D^{1/2}$  vs.  $V_G$  gives both  $\mu_{sat}$  and  $V_T$



Pinch off  
Drain

# Above threshold

- Source electrons can enter the channel at will.
- Channel is converted to n-type to conduct electrons that have entered the channel.



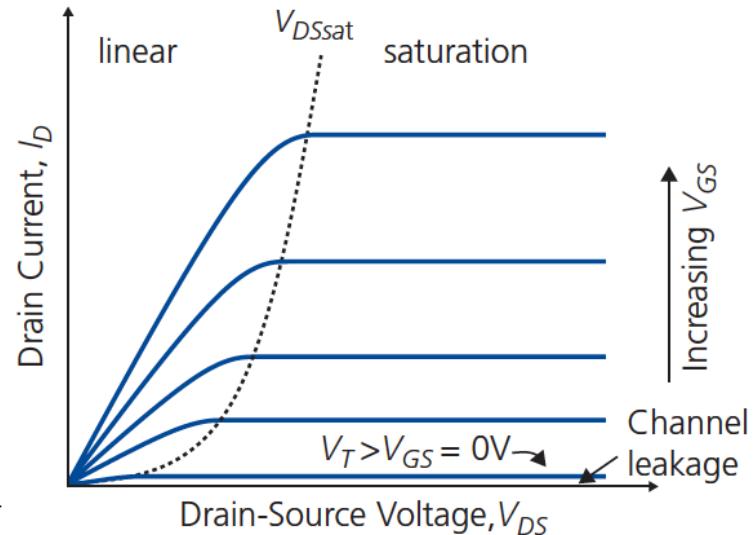
# Ideal Unipolar OTFT Characteristics

$$I_{DS} = \frac{Z}{L} \mu_n C_{ox} \left( V_{GS} - V_T - \frac{V_{DS}}{2} \right) V_{DS}$$

$$|V_{DS}| < |V_{GS} - V_T|$$

$$I_{DS} = \frac{Z}{2L} \mu_n C_{ox} (V_{GS} - V_T)^2$$

$$|V_{DS}| > |V_{GS} - V_T| = V_{Dsat}$$



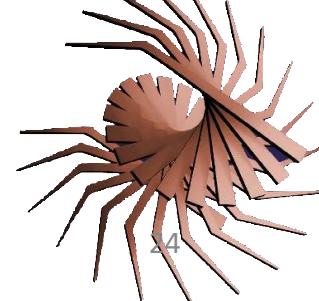
Output conductance (slope of the output characteristics)

$$g_D = \frac{\partial I_{DS}}{\partial V_{DS}} \Big|_{V_G=\text{constant}} = \begin{cases} \frac{Z}{L} \mu_n C_{ox} (V_{GS} - V_T - V_{DS}) & \text{Below } V_{Dsat} (\text{pinch-off}) \\ 0 & \text{Above } V_{Dsat} \end{cases}$$

Transconductance (rapidity of change of drain current with input voltage = "gain")

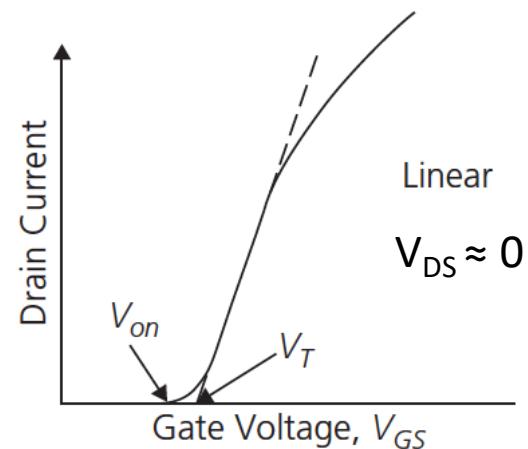
$$g_m = \frac{\partial I_{DS}}{\partial V_{GS}} \Big|_{V_{DS}=\text{constant}} = \begin{cases} \frac{Z}{L} \mu_n C_{ox} V_{DS} & \text{Below } V_{dsat} \\ \frac{Z}{L} \mu_n C_{ox} (V_{GS} - V_T) & \text{Above } V_{dsat} \end{cases}$$

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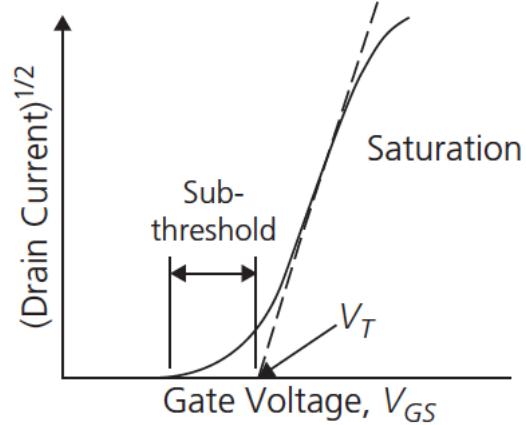


# OTFT Transfer Characteristics

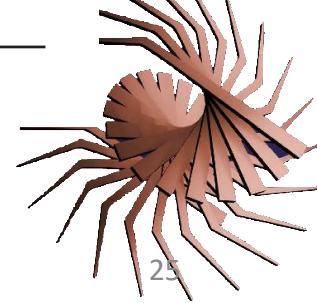
$$I_{DS} = \frac{Z}{L} \mu_n C_{ox} \left( V_{GS} - V_T - \frac{V_{DS}}{2} \right) V_{DS}$$



$$I_{DS} = \frac{Z}{2L} \mu_n C_{ox} (V_{GS} - V_T)^2$$

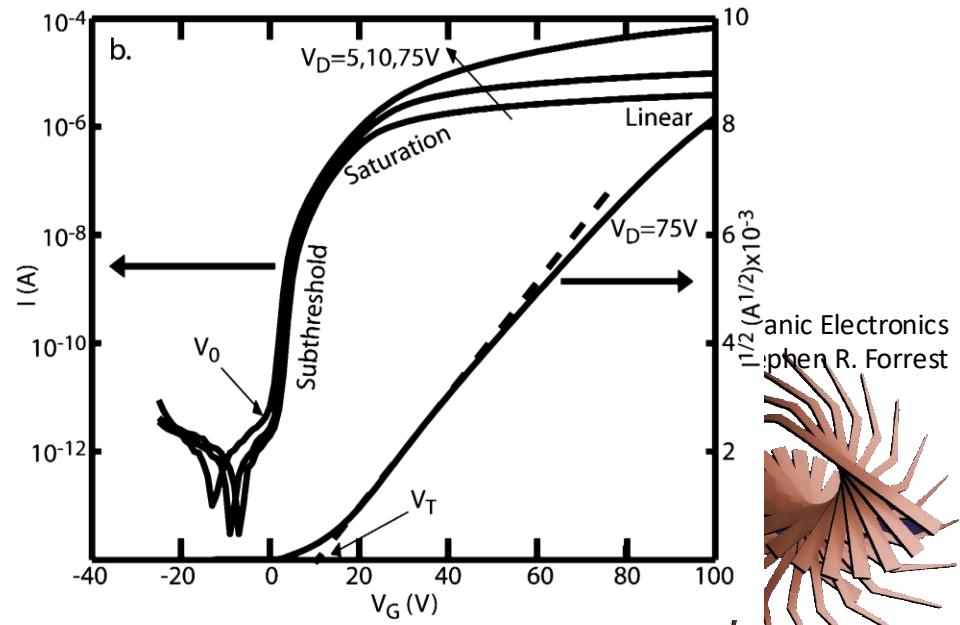
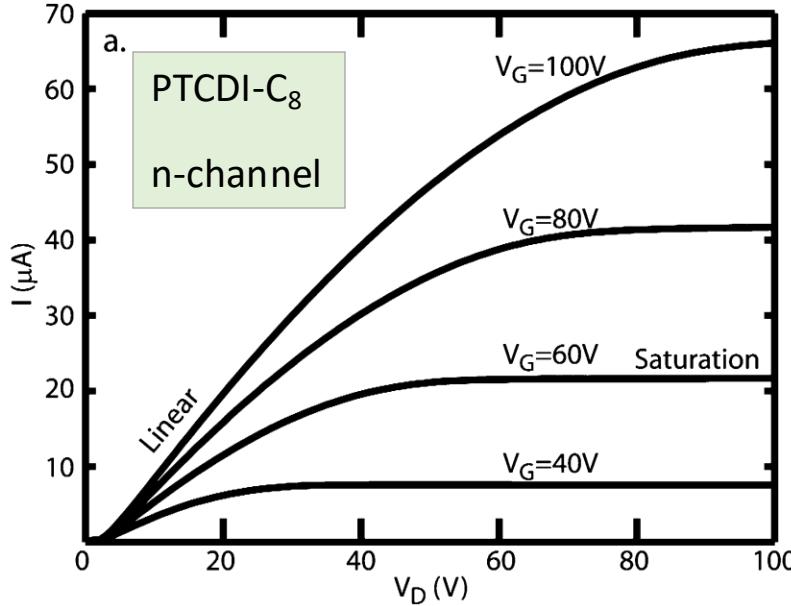


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# DC Characteristics of an OTFT

- Pentacene historically most frequently employed small molecule for OTFT (but not the best)
- $\mu_{FE} \sim 1 - 1.5 \text{ cm}^2/\text{V-s}$
- DC mobility as high as  $40 \text{ cm}^2/\text{V-s}$  measured in rubrene using OTFTs: is it reliable? (Takeya, et al. Appl. Phys. Lett. **90** 102120 (2007))
- OTFTs measure interface conductance, not mobility.

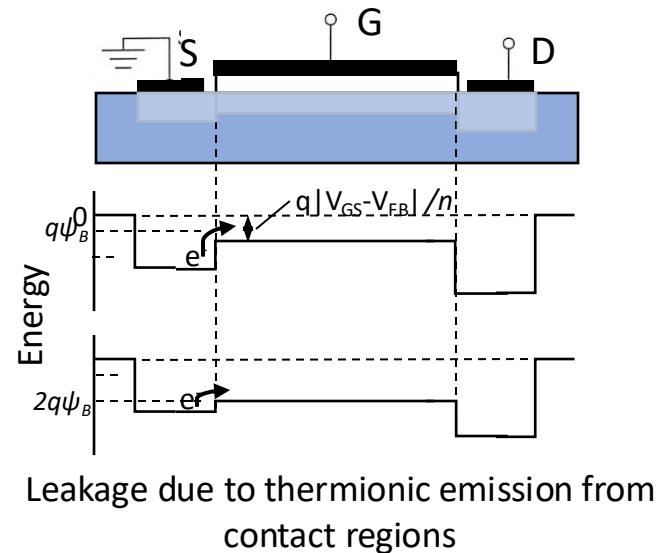


# Subthreshold slope

- Measure of how small a voltage swing needed to turn on a transistor
- Determines noise margin of a circuit (i.e. how easy is it for a “1” to be mistaken for a “0”)
- Low power digital circuits often operated in subthreshold regime

Definition:  $S = \frac{\partial V_{GS}}{\partial (\log_{10} I_D)}$

@  $V_{on} < V_{GS} < V_T$

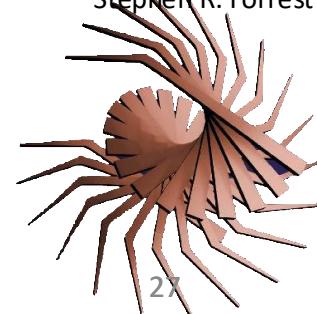


Imperfect contacts, traps lead to injection barrier at source:

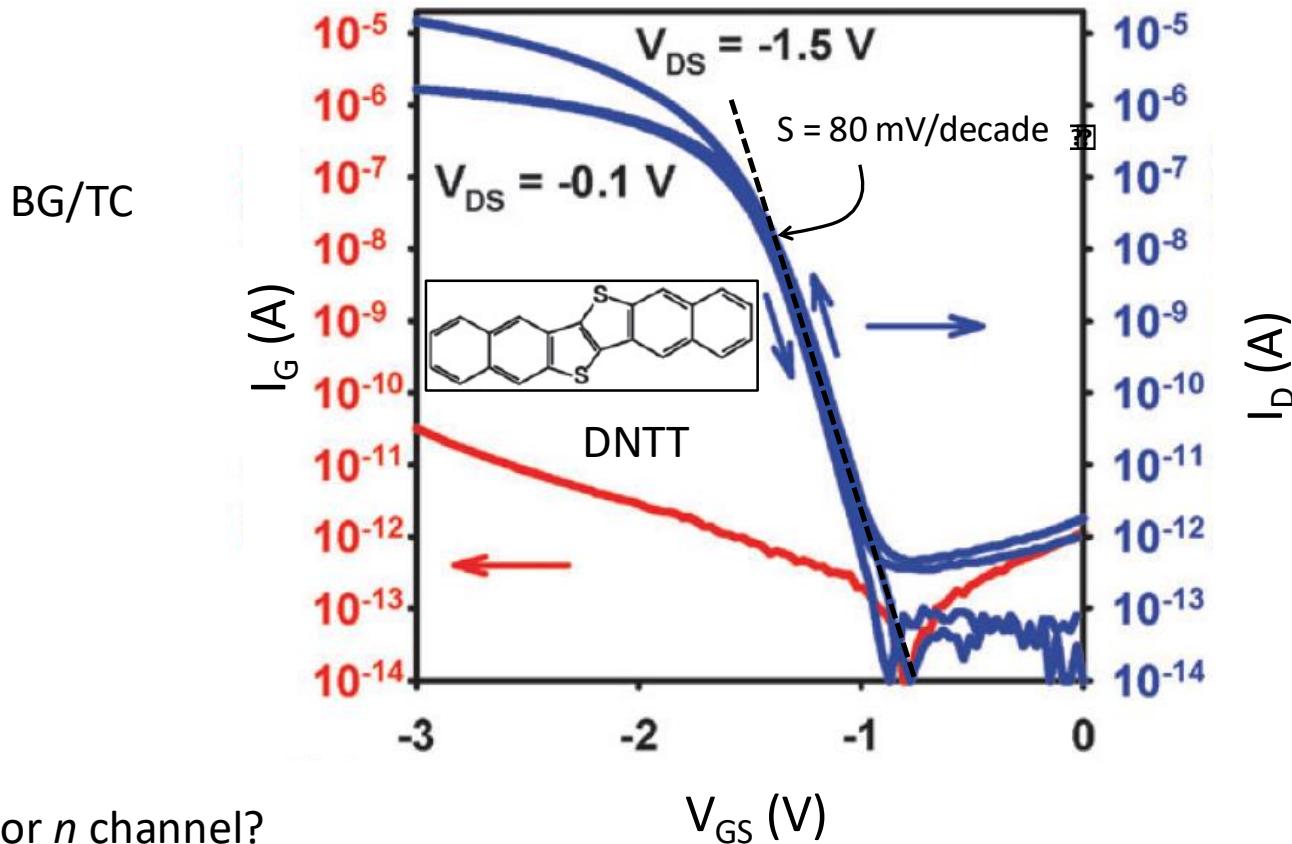
$$I_D = I_{D0} \exp\left(q|V_{GS} - V_{FB}|/nk_B T\right) = I'_{D0} \exp\left(qV_{GS}/nk_B T\right)$$

$$\Rightarrow S = 2.3 \frac{nk_B T}{q} \quad n = 1 \Rightarrow S = 60 \text{ mV/decade}$$

Theoretical minimum slope



# A high performance OTFT



- $p$  or  $n$  channel?
- $L/W = 10 \mu\text{m}/100 \mu\text{m}$
- Al gate
- $\text{AlO}_x$  gate insulator, 3.6 nm thick, PVD grown coated with alkylphosphonic acid SAM

